

SUPPORT FOR THE AMENDMENTS

The present amendment amends claim 1. Support for the amendment to claim 1 is found at specification page 11, lines 1-10. It is believed that these amendments have not resulted in the introduction of new matter.

REMARKS

Claims 1-6 are currently pending in the present application. Claim 1 has been amended by the present amendment. Claims 5 and 6 stand withdrawn from consideration by the Examiner as being directed to a non-elected invention.

The rejection of claims 1-4 under 35 U.S.C. § 103(a) as being obvious over Nishikawa (U.S. Patent 7,482,111) in view of Vikesland (U.S. Patent 4,571,374) is obviated by amendment, with respect to claim 1, which incorporates into claim 1 the limitation that the lower layer (I) comprises a radiation-nonsensitive resin composition.

Amended claim 1 is now directed to a two-layer laminated film for forming bumps, wherein the two-layer laminated film comprises: a lower layer (I) comprising a radiation-nonsensitive resin composition including a polymer (A) having a structural unit represented by the formula (1), and an organic solvent (B); and an upper layer (II) comprising a negative radiation-sensitive resin (e.g., a radiation-sensitive resin) composition (See e.g., present specification at page 11, lines 1-10, page 28, lines 23-24, page 29, lines 1-2).

Unlike the claimed invention, wherein the lower layer comprises a radiation-nonsensitive resin composition, the composition of Nishikawa is a negative radiation-sensitive resin (e.g., a radiation-sensitive resin) composition (See e.g., abstract, column 2, lines 56-61, column 3, lines 1-56, column 4, lines 18-59). Nishikawa fails to disclose or suggest a two-layer laminated film comprising a lower layer comprising a radiation-nonsensitive resin composition, as presently claimed. Accordingly, Nishikawa fails to render obvious to a skilled artisan the two-layer laminated film of the present invention.

Unlike the claimed invention, wherein the lower layer comprises a radiation-nonsensitive resin composition and the upper layer comprises a negative radiation-sensitive resin (e.g., a radiation-sensitive resin) composition, Vikesland describes a laminated film wherein the first (outer) layer and the second (inner) layer are both positive acting (e.g., radiation-sensitive).

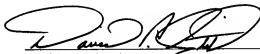
Vikesland fails to disclose or suggest the two-layer laminated film of the present invention comprising a lower layer comprising a radiation-nonsensitive resin composition, and an upper layer comprising a negative radiation-sensitive resin (e.g., a radiation-sensitive resin) composition. Accordingly, Vikesland fails to render obvious to a skilled artisan the two-layer laminated film of the present invention.

Withdrawal of these grounds of rejection is respectfully requested.

In conclusion, Applicants submit that the present application is now in condition for allowance and notification to this effect is earnestly solicited.

Respectfully submitted,

OBLON, SPIVAK, McCLELLAND,
MAIER & NEUSTADT, P.C.
Norman F. Oblon



David P. Stitzel
Attorney of Record
Registration No. 44,360

Customer Number
22850

Tel: (703) 413-3000
Fax: (703) 413 -2220
(OSMMN 06/04)